## AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the Application.

## **Listing of Claims**

- 1. (Currently Amended) A microbicidal composition comprising:
  - (a) 0.5 to 20 percent, based on weight of the composition, of halealkynyl-compoundone or more halopropargyl compounds;
  - (b) 0.3 to 10 percent, based on weight of the composition, of chelated metal ion compound wherein the chelated metal ion compound comprises a metal ion chelated with one or more amine chelating agents selected from the group consisting of alkylenepolyamines and carboxylate-containing amine compounds;
  - (c) 40 to 99 percent, based on weight of the composition, of water; and
  - (d) zero up to 30 percent, based on weight of the composition, of 3-isothiazolone compound.
- (Currently Amended) The composition of claim 1 wherein the haloalkynyl compound is
   halopropargyl compounds are selected from one or more of the group consisting of 3-iodo-2 propynylpropyl-carbamate, 3-iodo-2-propynylbutylcarbamate, 3-iodo-2 propynylhexylcarbamate, 3-iodo-2-propynylcyclohexylcarbamate and 3-iodo-2 propynylphenylcarbamate.
- (Original) The composition of claim 1 wherein the chelated metal compound comprises
  metal ion selected from one or more of copper, zinc, ferric, magnesium, cobalt and silver
  ions.
- 4. Cancelled
- 5. (Previously Amended) The composition of claim 1, wherein the chelated metal ion compound is in the form of a 1:1 molar complex of amine chelating agent and copper ion.
- 6. (Previously Amended) The composition of claim 1 wherein the amine chelating agent is selected from one or more of ethylenediaminetetraacetic acid and salts thereof, hydroxyethylenediaminetetraacetic acid and salts thereof, 1,3-diaminopropane-tetraacetic acid and salts thereof, 1,2-diaminocyclohexanetetraacetic acid and salts thereof, 1,2-propylenediaminetetraacetic acid and salts thereof, ethylene-diamine, propylenediamine, diethylenetriamine and triethylenetetraamine.

- 7. (Original) The composition of claim 1 comprising 1 to 25 percent of 3-isothiazolone compound.
- 8. (Original) The composition of claim 1, wherein the 3-isothiazolone compound is selected from one or more of 2-n-octyl-3-isothiazolone, 4,5-dichloro-2-n-octyl-3-isothiazolone, benzisothiazolone and N-alkyl derivatives of benzisothiazolone.
- 9. (Original) A microbicidal composition comprising:
  - (a) 5 to 10 percent, based on weight of the composition, of haloalkynyl compound selected from one or more of 3-iodo-2-propynylpropylcarbamate, 3-iodo-2-propynylbutylcarbamate, 3-iodo-2-propynylhexylcarbamate, 3-iodo-2-propynylphenylcarbamate;
  - (b) 2 to 5 percent, based on weight of the composition, of chelated metal ion compound, wherein the chelated metal ion compound is a 1:1 molar complex of amine chelating agent and copper ion and the amine chelating agent is selected from one or more of ethylenediaminetetraacetic acid and salts thereof, 1,3-diaminopropanetetraacetic acid and salts thereof, 1,2-propylenediaminetetraacetic acid and salts thereof, 1,2-diaminocyclohexanetetraacetic acid and salts thereof, and ethylenediamine;
  - (c) 60 to 70 percent, based on weight of the composition, of water,
  - (d) 10 to 20 percent, based on weight of the composition, of 3-isothiazolone compound selected from one or more of 2-n-octyl-3-isothiazolone, 4,5-dichloro-2-n-octyl-3-isothiazolone, benzisothiazolone and N-alkyl derivatives of benzisothiazolone; and
  - (e) zero up to 20 percent, based on weight of the composition, of adjuvants, selected from one or more of surfactants, dispersants and co-solvents.
- 10. (Currently Amended) A method of inhibiting the growth of microorganisms in a locus comprising introducing to, at or on, the locus a microorganism inhibiting amount of a microbicidal composition comprising:
  - (a) 0.5 to 20 percent, based on weight of the composition, of of halonlkynyl compoundone or more halopropargyl compounds;
  - (b) 0.3 to 10 percent, based on weight of the composition, of chelated metal ion compound wherein the chelated metal ion compound comprises a metal ion chelated with one or

more amine chelating agents selected from the group consisting of alkylenepolyamines and carboxylate-containing amine compounds;

- (c) 40 to 99 percent, based on weight of the composition, of water; and
- (d) zero up to 30 percent, based on weight of the composition, of 3-isothiazolone compound.